

Topographic and electronic contrast of the graphene moiré on Ir(111) probed by scanning tunneling microscopy and noncontact atomic force microscopy

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Epitaxial graphene grown on transition-metal surfaces typically exhibits a moiré pattern due to the lattice mismatch between graphene and the underlying metal surface. We use both scanning tunneling microscopy (STM) and atomic force microscopy (AFM) to probe the electronic and topographic contrast of the graphene moiré on the Ir(111) surface. STM topography is influenced by the local density of states close to the Fermi energy and the local tunneling barrier height. Based on our AFM experiments, we observe a moiré corrugation of 35 ± 10 pm, where the graphene-Ir(111) distance is the smallest in the areas where the graphene honeycomb is atop the underlying iridium atoms and larger on the fcc or hcp threefold hollow sites.

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Epitaxial graphene can be grown on many transition-metal surfaces using chemical vapor deposition (CVD).¹⁻³ This process gives ready access to high-quality, large scale, graphene monolayers on surfaces where graphene growth is self-terminating (e.g., Cu, Ir, Pt).^{1,2,4} These layers can be characterized by surface science techniques and, if necessary, transferred onto other substrates for further processing. The different metal surfaces can be coarsely classified based on how strongly the graphene layer interacts with the underlying metal substrate.⁵ For example, Ir(111) and Pt(111) surfaces interact weakly with the graphene layer and consequently, graphene still exhibits linear Dirac-like dispersion characteristic of isolated graphene.⁵⁻⁷ On the other hand, on Ru(0001) and Ni(111) surfaces, the graphene band structure is strongly modified.^{5,8} While the CVD growth occurs epitaxially, the lattice mismatch between graphene and the metal substrate gives rise to a moiré pattern that is observed on most metal surfaces [notably Ir(111),⁹⁻¹² Rh(111),¹³ Ru(0001),¹⁴⁻¹⁶ and Cu(111)¹⁷].

This moiré pattern can be readily observed by scanning tunneling microscopy (STM).^{9,14,17} However, STM images do not directly probe the topography of the surface; instead, the STM tip traces constant integrated local density of states (LDOS) surfaces at energies close to the Fermi level.^{18,19} This causes the contrast and apparent corrugation of the graphene moiré on Ir(111) to depend on the STM imaging conditions.^{9,10} It is not *a priori* clear which STM images correspond to the actual topography of the surface.

The use of a quartz tuning-fork force sensor in the QPlus configuration has made it possible to carry out noncontact atomic force microscopy (nc-AFM) in the frequency modulation mode with small tip oscillation amplitudes. This allows concurrent STM experiments, where the performance of the STM mode is not compromised by the tip oscillation or small force constant of the AFM cantilever.^{18,20-24} We have used this technique and performed both low-temperature AFM and STM measurements on epitaxial graphene monolayers on Ir(111) aimed at understanding the contributions of actual topography, charge transfer giving rise to local variations in the tunneling

barrier height and contact potential difference, and variations of the LDOS on the observed moiré pattern. These techniques give independent information on the surface topography, which allows separating electronic and topographic effects.

The graphene was grown on Ir(111) by CVD from ethylene.¹² The Ir(111) surface was first cleaned by repeated cycles of 3-kV Ar⁺-ion sputtering at room temperature followed by flashing to 1400 K and annealing at 1200 K. After the last annealing cycle, the sample was first annealed for 3 min at 800 K in 1×10^{-7} mbar O₂, then flashed to 1400 K before starting the CVD process. In order to ensure the formation of a full graphene monolayer, the sample was exposed to 5×10^{-7} mbar ethylene at 1250 K for 100 s. The sample was then transferred *ex situ* to the low-temperature STM/AFM system (LT-STM equipped with QPlus force sensor, Omicron Nanotechnology GmbH). Prior to the STM/AFM measurements, the sample was cleaned by heating to 800 K. All STM/AFM experiments were carried out in ultrahigh vacuum (base pressure $< 10^{-10}$ mbar) and at low temperature ($T = 4.7$ K). The QPlus sensor used for the frequency modulation nc-AFM experiments had a spring constant k of 1800 N/m, resonance frequency f_0 of ca. 24 kHz, and a quality factor of 18 800. We used PtIr tips and the tip oscillation amplitude was set to 5 Å. Bias voltage (V_{bias}) was applied on the sample with respect to the tip. dI/dV_{bias} and dI/dz signals were recorded with a lock-in amplifier by applying a small sinusoidal variation to the bias voltage or the z -piezo position, respectively.

Figure 1(a) shows a constant-current STM topography image of a graphene monolayer on Ir(111). In addition to the atomically resolved hexagonal graphene structure, a moiré pattern with a period of 2.5 nm is clearly visible. It has been shown previously that this superstructure preferentially orients along the atomic rows of graphene, which is also the case in Fig. 1(a).¹⁰ The apparent peak to peak (p-p) corrugation of the moiré pattern is 50 pm. The unit cell of the moiré is indicated by the solid line, and the three inequivalent areas [with respect to the registry with the Ir(111) lattice] are indicated by A, B, and C. It has been previously suggested

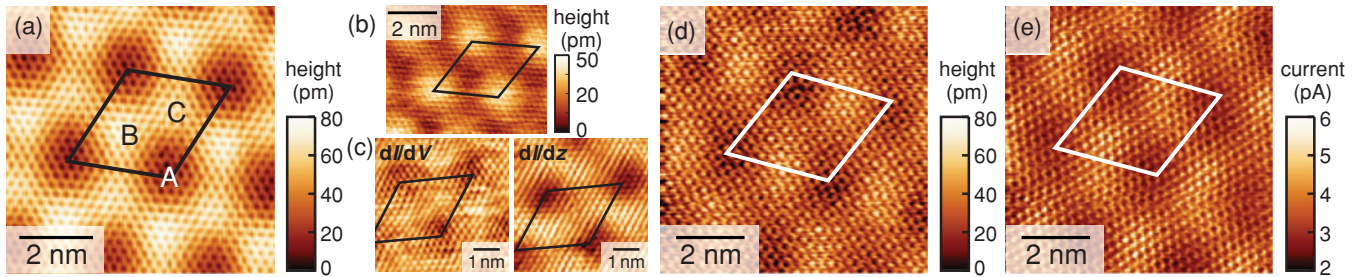


FIG. 1. (Color online) (a) Constant-current STM topography image of epitaxial graphene on Ir(111) acquired at $V_{\text{bias}} = 0.3$ V and set-point current of 0.3 nA. The line indicates the moiré unit cell and the three inequivalent areas within it are denoted by A, B, and C. (b) High-bias STM image taken at 0.45 V/1 nA showing the inverted moiré pattern. (c) Constant-current dI/dV and dI/dz maps recorded at a bias of 0.05 V. (d) Constant frequency shift nc-AFM image with $\Delta f = -45$ Hz and $V_{\text{bias}} = 0.01$ V. (e) Average current over the tip oscillation cycle measured simultaneously under AFM feedback.

that they correspond to areas where the graphene honeycomb is centered on the underlying Ir atoms (atop, A) or on the fcc (B) or hcp (C) threefold hollow sites.^{9,10} We observed that the apparent corrugation depends on tip conditions and systematically on the bias voltage, in agreement with earlier results.¹⁰ STM images at a higher bias [≥ 0.5 V, Fig. 1(b)] exhibit inverted moiré contrast (region A becomes bright) compared to low-bias images.

In addition to standard STM imaging, we can get further information on the local electronic properties by mapping out the LDOS ($\propto dI/dV_{\text{bias}}$) and the tunneling decay constant κ ($\propto dI/dz$) signals in the constant-current mode. These quantities vary over the moiré pattern, as shown in Fig. 1(c). Both LDOS and κ are lower at region A of the moiré.

As STM imaging is clearly influenced by electronic effects, we carried out low-temperature nc-AFM experiments in the constant frequency shift mode to probe the surface topography of graphene monolayer on Ir(111). Figure 1(d) shows a typical AFM topography image [the image was not recorded on the precise location of the image shown in Fig. 1(a)]. In addition to the contrast on the atomic scale, we obtain a moiré pattern with similar contrast as in STM imaging and an apparent corrugation of ca. 30 pm. Careful inspection of Fig. 1(d) reveals variations in the atomic scale contrast. On the bright areas of the moiré pattern, the carbon atoms are imaged as depressions, in line with the earlier atomically resolved images of carbon nanotubes.²⁵ The observed contrast changes on the dark areas, indicating that the tip-graphene distance is different on the different regions of the moiré pattern (see below).

The simultaneously measured tunneling current during the nc-AFM imaging is shown in Fig. 1(e). It again shows both atomic and moiré contrast, where the low-current regions are aligned with the depressions in the topographic image. Note that there is a shift between the AFM image and simultaneously measured tunneling current. It is likely that the tip has an impurity (atom) that does not contribute to the current but has an effect on the measured frequency shift. Alternatively, an asymmetric tip apex can cause the shift between AFM and average current images.²⁶ We find the same qualitative moiré contrast with different tips and on different locations of the sample.

The tip-sample interaction causes a shift Δf in the resonance frequency of the cantilever. At small tip oscillation amplitudes, the measured detuning is directly proportional to

force gradient $\Delta f = -f_0/(2k)(\partial F_{\text{ts}}/\partial z)$, where F_{ts} is the total interaction force between tip and sample.¹⁸ Different forces contribute to F_{ts} , the most relevant in our experiment being quantum mechanical forces between the tip apex and the surface (Pauli repulsion, chemical bonding), van der Waals (vdW) interactions between the tip and graphene and the tip and the Ir substrate, and electrostatic forces.^{18,19,23} AFM topography might also be affected by chemical inhomogeneity of the surface (different regions of the graphene moiré are known to have different chemical reactivities^{9,13,14}). However, we have observed the same qualitative moiré contrast with different tip terminations, consistent with the expected weak interaction between graphene and the Ir(111) surface.

Experimental results based on angle-resolved photoemission and x-ray photoelectron spectroscopies and *ab initio* calculations show that the interaction between graphene and iridium is weak.^{5,6,9,27} Theoretical calculations give an average graphene-Ir(111) distance of about 3.9 Å (generalized gradient approximation (GGA)-density-functional theory (DFT)) or 3.42 Å (local density approximation (LDA)-DFT).^{9,27} It is well-known that GGA underestimates and LDA overestimates binding in systems where vdW interactions are important. Recent DFT calculations using vdW-corrected functionals have found binding distances of 3.6–3.7 Å for graphene on weakly interacting metals (e.g., Pt).²⁸ Despite the large binding distance, it is important to realize that the vdW forces between the tip and the sample are sufficiently long range to include contributions from the iridium substrate. In the attractive regime, the background vdW from the Ir substrate results in increased attraction in the area A of the moiré, which causes the AFM feedback to increase tip-sample distance in order to keep Δf constant. Hence, the AFM corrugation underestimates the real topographic corrugation of the graphene moiré as illustrated in Fig. 2(a).

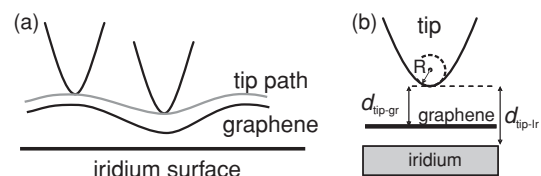


FIG. 2. (a) Schematic representation of the tip movement over graphene. (b) Variables used in Eq. (1).

We now model this effect within the small amplitude approximation (detuning proportional to force gradient). This approximation is valid if the force gradient is roughly constant throughout the oscillation cycle of the tip. We use relatively small oscillation amplitudes and consider here only the vdW interactions that are relevant for the AFM observation of the moiré pattern on an otherwise chemically homogeneous surface. The chemical interactions between the tip apex and the surface only act at very short distances (much smaller than our tip oscillation amplitude), whereas the long-range electrostatic force remains almost constant over the oscillation cycle assuming that neither the tip nor the surface is charged. Consequently, these forces make only a minor contribution to the observed AFM response.

The total vdW force felt by the tip [modeled as a paraboloid $z = x^2/(2R)$, where R is the tip radius] can be calculated by integrating the vdW potential $w_{\text{vdw}} = -4\epsilon(\sigma/r)^6$ over the tip and Ir bulk, and tip and two-dimensional graphene layer.¹⁹ We assume that the vdW interaction between the tip and Ir substrate is not screened by the graphene layer. Hence, we obtain an estimate of the upper limit of the background vdW contribution. The derivative of the total force is then proportional to the detuning Δf of the tip

$$\Delta f = -\frac{f_0 R}{2k} \left(\frac{\sqrt{A_{\text{tip}} A_{\text{Ir}}}}{3d_{\text{tip-Ir}}^3} + \frac{\sqrt{A_{\text{tip}} A_{\text{HOPG}}}}{d_{\text{tip-gr}}^4} \right), \quad (1)$$

where $A_i = 4\pi^2 \epsilon_i \rho_i^2 \sigma_i^6$ is the Hamaker constant and $d_{\text{tip-Ir}}$ and $d_{\text{tip-gr}}$ are the tip-Ir and tip-graphene distances corresponding to the midpoint of the tip oscillation cycle. In the case of a two-dimensional layer, the vdW force depends on the surface atom density rather than the volume density. We take this into account by using the HOPG Hamaker constant A_{HOPG} and the layer density l_{HOPG} .

In Eq. (1) the first term is the detuning caused by the tip-Ir vdW force and the second term the tip-graphene vdW force. The relation of these terms is illustrated in Fig. 3(a), where we plot them (and the total Δf) as a function of the tip-graphene distance. The contribution from the Ir substrate increases and even becomes the dominant term at large distances.

We have solved the tip-graphene distance $d_{\text{tip-gr}}$ from Eq. (1) numerically as a function of the graphene-Ir distance ($d_{\text{tip-Ir}} - d_{\text{tip-gr}}$) [Fig. 3(b)]. $d_{\text{tip-gr}}$ changes almost linearly over a reasonable range of graphene-Ir distances. The slope s of this curve represents the underestimation of corrugation on the moiré due to the background vdW forces from the Ir bulk. Thus, the real geometric corrugation of the moiré is given by $a_{\text{real}} = (1 - s)a_{\text{AFM}}$. The Hamaker constants have a fairly small effect on the slope, whereas R and Δf have quite a significant effect. This is illustrated in Fig. 3(c), where we plot the average slope in the range of $d_{\text{gr-Ir}}$ between 3 and 4 Å. This effect can be easily understood by the fact that Δf and R determine the absolute tip-graphene distance, which governs the proportion of the vdW force from the bulk Ir with respect to the total force. While our estimation of $d_{\text{tip-gr}}$ depends on R , which is difficult to estimate independently, we can also estimate $d_{\text{tip-gr}}$ based on the simultaneously recorded tunneling current. Taking into account the tip oscillation¹⁸ and using a measured value of the tunneling decay constant $\kappa \approx 0.55 \text{ \AA}^{-1}$, we can extrapolate the distance to point contact.

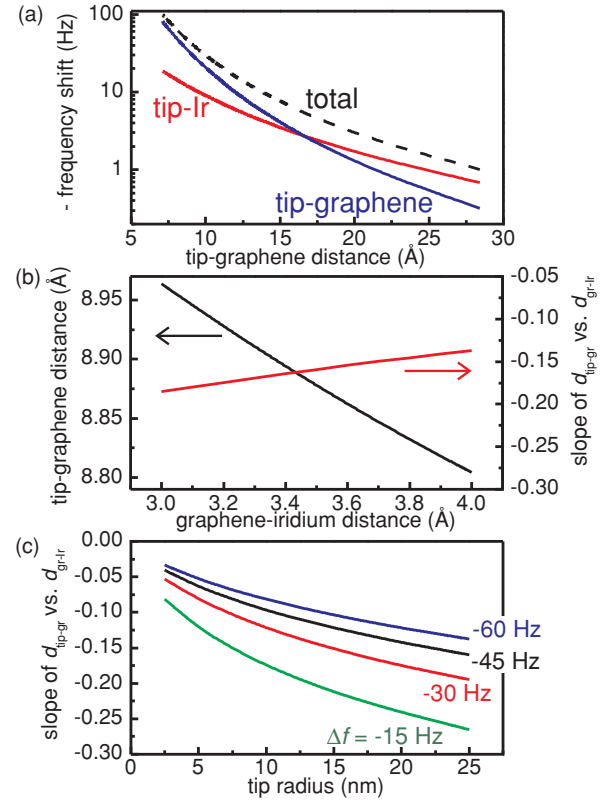


FIG. 3. (Color online) Theoretical modeling of the vdW forces in the AFM tip-graphene-Ir substrate system. (a) The contributions of graphene and iridium substrate to the total Δf . (b) Tip-graphene distance as a function of graphene-Ir distance calculated with $\Delta f = -45$ Hz. The corresponding slope is plotted on the right y axis. (c) Slope s of the $d_{\text{tip-Ir}}$ vs $d_{\text{tip-gr}}$ curve for different tip radii and different Δf (indicated in the figure). Panels (a) and (b) are calculated with $R = 10$ nm, $A_{\text{HOPG}} = 3.42 \times 10^{-19}$ J, $A_{\text{tip}} = A_{\text{Ir}} = 4 \times 10^{-19}$ J,^{29,30} and $l_{\text{HOPG}} = 1/335.4$ pm were used in all calculations.

This procedure gives an average tip-graphene distance of 7.2 Å in Fig. 1(d).

The data shown in Fig. 3(c) shows that even though the background vdW from the Ir bulk affects the apparent AFM corrugation, the effect is rather small. The correction factor is 10%–20% for reasonable tip radii and at sufficiently negative Δf , which yields 35 ± 10 pm as our estimation for the actual moiré corrugation. It should be noted that this model does not take the actual shape of the corrugation of the moiré into account. It only corrects the measured corrugation by the background vdW from the Ir bulk. Due to the relatively equal scale of curvature of the tip and the moiré, the corrugation may be slightly further underestimated by AFM measurements.

The increase in the tip-graphene distance caused by the increased background vdW interaction between the tip and the Ir substrate in the area A of the moiré reduces the tunneling current as seen in Fig. 1(c). However, if we use the estimated changes in $d_{\text{tip-gr}}$, we obtain a current variation of only ca. 10%. On the other hand, the experimentally measured variation is much larger, about a factor of 2. Apart from the $d_{\text{tip-gr}}$, the tunneling current is influenced by the LDOS and the

decay constant κ . Both of these quantities vary over the moiré pattern as shown in Fig. 1(c). These quantities have opposite effects on the tunneling current: The larger the LDOS, the larger is the current. On the other hand, the larger the decay constant, the smaller the current as it is proportional to $\exp(-2\kappa d_{\text{tip-gr}})$. Our observations then imply that at small bias, the reduced LDOS in the region A of the moiré is (mostly) responsible for the reduced tunneling current in the simultaneously measured tunneling current images under AFM feedback. This conclusion naturally does not hold for increased bias ($\gtrsim 0.5$ V) where the STM contrast of the moiré pattern is inverted.

We can relate the STM to AFM results by switching *in situ* back and forth between STM and AFM feedback. Qualitatively, the moiré contrast is the same between AFM and low-bias STM images (dark depressions in a bright background). We do not have a direct measure of the registry between the moiré unit cell and the underlying iridium lattice. However, comparison of our STM results with the STM-based graphene adsorption site determination^{9,10,27} relates the regions of the moiré unit cell to areas where the graphene honeycomb is centered atop the underlying Ir atoms (A), or on the fcc (B) or hcp (C) threefold hollow sites. Thus, our STM and AFM measurements seem to imply that graphene-Ir(111)

distance is the smallest on atop sites (region A) and larger on fcc and hcp sites (regions B and C). This is surprising and in contrast to other graphene-metal systems.

In conclusion, we have carried out simultaneous low-temperature AFM and STM experiments on an epitaxial graphene monolayer on the Ir(111) surface. These experiments shed light on the structure of the graphene moiré on the Ir(111) surface. While STM experiments are dominated by electronic effects, nc-AFM provides a qualitatively correct image of the surface topography. A more quantitative estimation of the moiré corrugation based on the AFM experiments would require accounting for the background vdW interaction between the tip and the metallic substrate. Although in the present case of graphene on Ir(111) the background effect is small, it has to be considered in principle for quantitative topography of atomically thin two-dimensional layers deposited on solid substrates.

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